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## BIB DATA SHEET

CONFIRMATION NO. 5838

<b>SERIAL NUMBER</b> 10/598,471	<b>FILING or 371(c) DATE</b> 08/31/2006 <b>RULE</b>	<b>CLASS</b> 501	<b>GROUP ART UNIT</b> 1793	<b>ATTORNEY DOCKET NO.</b> OGOSH59USA		
<b>APPLICANTS</b> Yuichiro Shindo, Ibaraki, JAPAN; Akira Hisano, Ibaraki, JAPAN; <b>** CONTINUING DATA *****</b> This application is a 371 of PCT/JP05/01488 02/02/2005 <b>** FOREIGN APPLICATIONS *****</b> JAPAN 2004-056022 03/01/2004 <b>** IF REQUIRED, FOREIGN FILING LICENSE GRANTED **</b> 07/11/2007						
Foreign Priority claimed <input checked="" type="checkbox"/> Yes <input type="checkbox"/> No 35 USC 119(a-d) conditions met <input checked="" type="checkbox"/> Yes <input type="checkbox"/> No Verified and <u>/VANESSA T VELASQUEZ/</u> Acknowledged <u>Examiner's Signature</u>		<input checked="" type="checkbox"/> Met after Allowance VTV <u>Initials</u>	<b>STATE OR COUNTRY</b> JAPAN	<b>SHEETS DRAWINGS</b> 0	<b>TOTAL CLAIMS</b> 19	<b>INDEPENDENT CLAIMS</b> 3
<b>ADDRESS</b> HOWSON & HOWSON LLP 501 OFFICE CENTER DRIVE SUITE 210 FORT WASHINGTON, PA 19034 UNITED STATES						
<b>TITLE</b> High- Purity Ru Powder, Sputtering Target Obtained by Sintering the Same, Thin Film Obtained by Sputtering the Target and Process for Producing High-Purity Ru Powder						
<b>FILING FEE RECEIVED</b> 900	FEES: Authority has been given in Paper No. _____ to charge/credit DEPOSIT ACCOUNT No. _____ for following:			<input type="checkbox"/> All Fees <input type="checkbox"/> 1.16 Fees (Filing) <input type="checkbox"/> 1.17 Fees (Processing Ext. of time) <input type="checkbox"/> 1.18 Fees (Issue) <input type="checkbox"/> Other _____ <input type="checkbox"/> Credit		